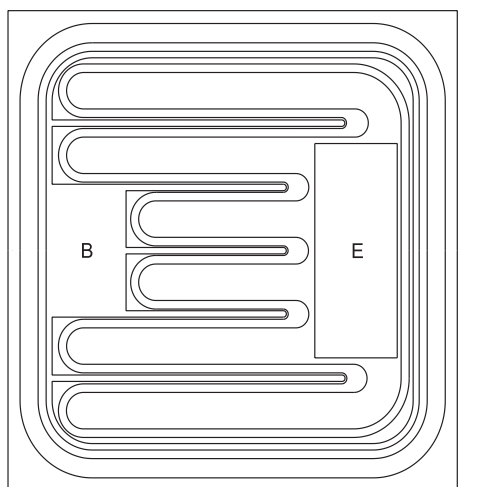


PROCESS DETAILS

Process	EPITAXIAL PLANAR
Die Size	87 x 87 MILS
Die Thickness	9.0 MILS
Base Bonding Pad Area	24 x 15 MILS
Emitter Bonding Pad Area	38 x 16 MILS
Top Side Metalization	Al - 30,000Å
Back Side Metalization	Ti/Ni/Ag - 11,000Å

GEOMETRY

BACKSIDE COLLECTOR R0

GROSS DIE PER 4 INCH WAFER

1,460

PRINCIPAL DEVICE TYPES

CZTA44HC

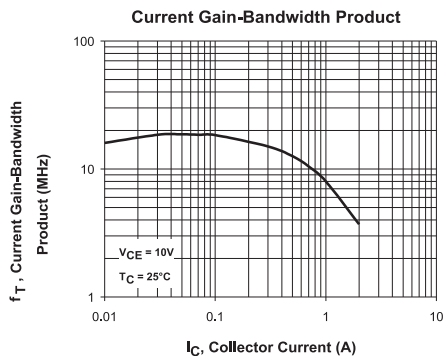
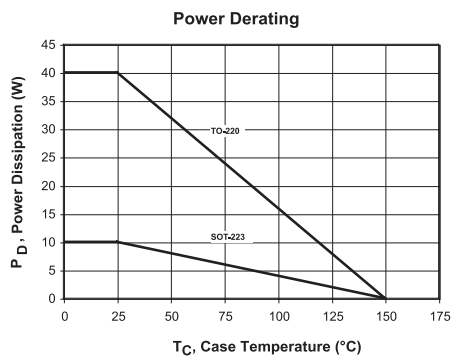
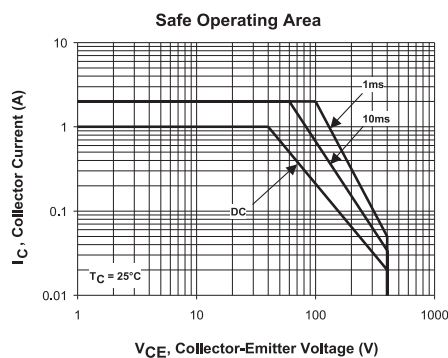
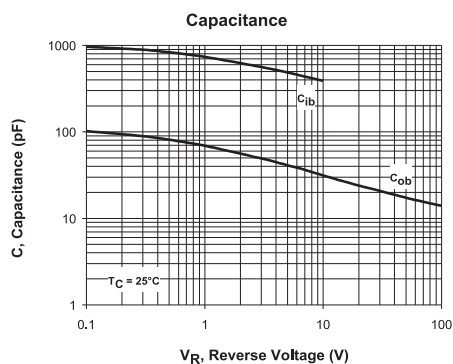
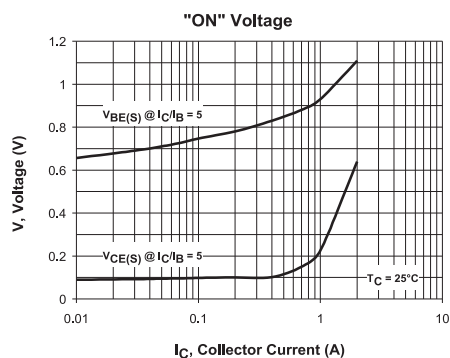
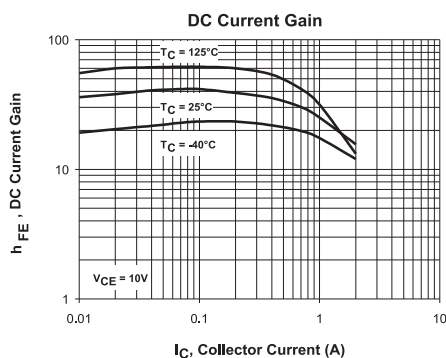
TIP47

TIP48

TIP50

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